



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:

SABNIS, RAM et al.

Serial No.: 10/657,436

Filed: September 8, 2003

PHOTORESISTIVE BLACK MATRIX

Docket No.: 30545-CNT4

Group Art Unit No.: 1756

Examiner: Angebranndt, Martin J.

Commissioner of Patents
P.O. Box 1450
Alexandria, VA 22313-1415

Sir:

INFORMATION DISCLOSURE STATEMENT

The attached references are being filed to fulfill the duty of candor and good faith toward the Patent and Trademark Office, as required by 37 C.F.R. §1.56.

Any fee which is due in connection with this Statement should be applied against Deposit Account No. 19-0522.

Respectfully submitted,

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FORM PTO-1449 (Rev. 2-32)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. 30545-CNT4	SERIAL NO. 10/647,436
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)		APPLICANT: SABNIS, et al.	
		FILING DATE: September 8, 2003	GROUP: 1756

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

		de Keyzer et al., Novel Black Photoresists with High Photospeed and High Optical Density Based on Laten Pigments, <i>International display Workshop</i> , 291 (1998)
		Asuma et al., Electrical Characteristics of Black Mtrix for Super-TFT-LCDs, <i>International Display Workshop</i> , pp. 167-170

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.